Amendments to the Claims:

This listing of claims will replace all prior versions and listings of claims in the application.

Listing of Claims:

1. (Amended) An acrylic copolymer comprising: a recurring unit of the following formula (1),

a recurring unit of the following formula (2),

wherein R represents a hydrogen atom or a methyl group; R¹ individually represents a hydrogen atom, hydroxyl group, or -COOR³ group, wherein R³ is a hydrogen atom, a linear or branched alkyl group having 1-4 carbon atoms or an alicyclic alkyl group

having 3-20 carbon atoms, provided that at least one of R¹ groups is not a hydrogen atom, and

a recurring unit of the following formula (3),

$$\begin{array}{ccc}
H & H \\
C & C
\end{array}$$

$$\begin{array}{cccc}
C & R^2 \\
R^2 & R^2
\end{array}$$
(3)

wherein any two of R² groups form, in combination and together with the carbon atom to which the two R² groups bond, a divalent alicyclic hydrocarbon group having 4-20 carbon atoms or a derivative thereof, with the remaining R² being a linear or branched alkyl group having 1-4 carbon atoms, a monovalent alicyclic hydrocarbon group having 4-20 carbon atoms, or a derivative thereof.

- 2. (Original) A radiation-sensitive resin composition comprising an acid-labile group-containing resin which is insoluble or scarcely soluble in alkali, but becomes alkali soluble by the action of an acid, and a photoacid generator, wherein the acid-labile group-containing resin is the acrylic copolymer according to claim 1.
- 3. (Original) The radiation-sensitive resin composition according to claim 2, wherein at least one R¹ group in the formula (2) is a hydroxyl group.

- 4. (Original) The radiation-sensitive resin composition according to claim 2, wherein the group –C (R²)₃ in the formula (3) is at least one group selected from the group consisting of a 1-methyl-l-cyclopentyl group, a l-ethyl-l-cyclopenthyl group, a 1-methyl-l-cyclohexyl group, and a l-ethyl-l-cyclohexyl group.
- 5. (Original) The radiation-sensitive resin composition according to claim 2, wherein the acid-labile group-containing resin comprises the recurring unit (1), recurring unit (2), and recurring unit (3) at a molar ratio (mol% of the total recurring units) of 20-70: 5-40: 20-50.
- 6. (Original) The radiation-sensitive resin composition according to claim 2, wherein the photoacid generator comprises at least one compound selected from the group consisting of a triphenylsulfonium salt compound, a 4-cyclohexylphenyldiphenylsulfonium salt compound, a 4-t-butylphenyldiphenylsulfonium salt compound, and a tri(4-t-butylphenyl)sulfonium salt compound.
- 7. (Original) The radiation-sensitive resin composition according to claim 2, wherein the amount of photoacid generator is 0.1-7 parts by weight for 100 parts by weight of the acrylic copolymer.
- 8. (Original) The radiation-sensitive resin composition according to claim 2, further comprising an acid diffusion controller, wherein the acid diffusion controller is a

nitrogen-containing organic compound.

- 9. (Original) The radiation-sensitive resin composition according to claim 2, wherein after post exposure baking the size of contact hole patterns is reduced at an excellent precision by post development baking.
- 10. (Original) The radiation-sensitive resin composition according to claim 2, wherein any two of R² groups in the formula (3) of the acid-labile group-containing resin form, in combination and together with the carbon atom to which these R² groups bond, a divalent monocyclic alicyclic hydrocarbon group having 4-20 carbon atoms or a derivative thereof, with the remaining R² group being a linear or branched alkyl group having 1-4 carbon atoms, a monovalent alicyclic hydrocarbon group having 4-20 carbon atoms, or a derivative thereof.
- 11. (Currently Amended) The radiation-sensitive resin composition according to claim 10, wherein the divalent monocyclic alicyclic hydrocarbon group having 4-20 carbon atoms is a eyclopentyl cycloheptyl group or a cyclohexyl group.
- 12. (Original) An acrylic copolymer consisting essentially of: a recurring unit of the following formula (1),

a recurring unit of the following formula (2),

wherein R represents a hydrogen atom or a methyl group; R¹ individually represents a hydrogen atom, hydroxyl group, or -COOR³ group, wherein R³ is a hydrogen atom, a linear or branched alkyl group having 1-4 carbon atoms, or an alicyclic alkyl group having 3-20 carbon atoms, provided that at least one of R¹ groups is not a hydrogen atom, and a recurring unit of the following formula (3),

$$\begin{array}{ccc}
H & H \\
 & C & C & C & C \\
 &$$

wherein any two of R² groups form, in combination and together with the carbon atom to which the two R² groups bond, a divalent alicyclic hydrocarbon group having 4-20 carbon atoms or a derivative thereof, with the remaining R² being a linear or branched alkyl group having 1-4 carbon atoms, a monovalent alicyclic hydrocarbon group having 4-20 carbon atoms, or a derivative thereof.

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